



NSAI
Standards

Irish Standard Recommendation
S.R. CEN/TS 17629:2021

Nanotechnologies - Nano- and micro-scale scratch testing

S.R. CEN/TS 17629:2021

Incorporating amendments/corrigenda/National Annexes issued since publication:

The National Standards Authority of Ireland (NSAI) produces the following categories of formal documents:

I.S. xxx: Irish Standard — national specification based on the consensus of an expert panel and subject to public consultation.

S.R. xxx: Standard Recommendation — recommendation based on the consensus of an expert panel and subject to public consultation.

SWiFT xxx: A rapidly developed recommendatory document based on the consensus of the participants of an NSAI workshop.

This document replaces/revises/consolidates the NSAI adoption of the document(s) indicated on the CEN/CENELEC cover/Foreword and the following National document(s):

NOTE: The date of any NSAI previous adoption may not match the date of its original CEN/CENELEC document.

This document is based on:

CEN/TS 17629:2021

Published:

2021-06-16

*This document was published
under the authority of the NSAI
and comes into effect on:*

2021-07-04

ICS number:

07.120

NOTE: If blank see CEN/CENELEC cover page

NSAI
1 Swift Square,
Northwood, Santry
Dublin 9

T +353 1 807 3800
F +353 1 807 3838
E standards@nsai.ie
W NSAI.ie

Sales:
T +353 1 857 6730
F +353 1 857 6729
W standards.ie

Údarás um Chaighdeáin Náisiúnta na hÉireann

National Foreword

S.R. CEN/TS 17629:2021 is the adopted Irish version of the European Document CEN/TS 17629:2021, Nanotechnologies - Nano- and micro- scale scratch testing

This document does not purport to include all the necessary provisions of a contract. Users are responsible for its correct application.

For relationships with other publications refer to the NSAI web store.

Compliance with this document does not of itself confer immunity from legal obligations.

In line with international standards practice the decimal point is shown as a comma (,) throughout this document.

This page is intentionally left blank

TECHNICAL SPECIFICATION
SPÉCIFICATION TECHNIQUE
TECHNISCHE SPEZIFIKATION

CEN/TS 17629

June 2021

ICS 07.120

English Version

Nanotechnologies - Nano- and micro- scale scratch testing

Nanotechnologies - Essais de rayure aux échelles nano-
et micro métriques

Nanotechnologien - Nano- und Mikro-Ritzprüfung

This Technical Specification (CEN/TS) was approved by CEN on 9 May 2021 for provisional application.

The period of validity of this CEN/TS is limited initially to three years. After two years the members of CEN will be requested to submit their comments, particularly on the question whether the CEN/TS can be converted into a European Standard.

CEN members are required to announce the existence of this CEN/TS in the same way as for an EN and to make the CEN/TS available promptly at national level in an appropriate form. It is permissible to keep conflicting national standards in force (in parallel to the CEN/TS) until the final decision about the possible conversion of the CEN/TS into an EN is reached.

CEN members are the national standards bodies of Austria, Belgium, Bulgaria, Croatia, Cyprus, Czech Republic, Denmark, Estonia, Finland, France, Germany, Greece, Hungary, Iceland, Ireland, Italy, Latvia, Lithuania, Luxembourg, Malta, Netherlands, Norway, Poland, Portugal, Republic of North Macedonia, Romania, Serbia, Slovakia, Slovenia, Spain, Sweden, Switzerland, Turkey and United Kingdom.



EUROPEAN COMMITTEE FOR STANDARDIZATION
COMITÉ EUROPÉEN DE NORMALISATION
EUROPÄISCHES KOMITEE FÜR NORMUNG

CEN-CENELEC Management Centre: Rue de la Science 23, B-1040 Brussels

CEN/TS 17629:2021 (E)

Contents	Page
European foreword.....	3
Introduction	3
1 Scope	5
2 Normative references	5
3 Terms and definitions	5
4 Symbols and abbreviations	7
5 Principle	9
5.1 General.....	9
5.2 Friction.....	9
5.3 Factors influencing the critical forces	9
5.4 Multiple pass testing	11
6 Apparatus and materials	12
6.1 Apparatus.....	12
6.2 Probes.....	14
6.3 Test environment.....	16
7 Preparation of test-pieces.....	16
7.1 Roughness.....	16
7.2 Test-piece cleaning.....	16
8 Test procedures	17
8.1 General.....	17
8.2 Zero-point determination	17
8.3 Test force.....	18
8.4 Test profiles	18
8.5 Test procedures	18
9 Analysis of results	23
9.1 General.....	23
9.2 Single pass ramping force	23
9.3 Single pass constant force	26
9.4 Multi-pass ramping force	26
9.5 Multi-pass constant force	26
10 Test reproducibility, repeatability and limits	27
11 Test report.....	28
Annex A (normative) Procedures for determination of probe area function or radius function	29
Bibliography.....	34

European foreword

This document (CEN/TS 17629:2021) has been prepared by Technical Committee CEN/TC 352 “Nanotechnologies”, the secretariat of which is held by AFNOR.

Attention is drawn to the possibility that some of the elements of this document may be the subject of patent rights. CEN shall not be held responsible for identifying any or all such patent rights.

According to the CEN/CENELEC Internal Regulations, the national standards organisations of the following countries are bound to announce this Technical Specification: Austria, Belgium, Bulgaria, Croatia, Cyprus, Czech Republic, Denmark, Estonia, Finland, France, Germany, Greece, Hungary, Iceland, Ireland, Italy, Latvia, Lithuania, Luxembourg, Malta, Netherlands, Norway, Poland, Portugal, Republic of North Macedonia, Romania, Serbia, Slovakia, Slovenia, Spain, Sweden, Switzerland, Turkey and the United Kingdom.

CEN/TS 17629:2021 (E)

Introduction

The test procedure is intended to complement other standards which are concerned with the scratch resistance of materials. This procedure extends the use of the nano- and micro- single pass scratch test to bulk and coated materials, additionally covering the use of multiple pass nano- and micro- scratch tests.

The method described is not intended to be used to define how particles are released from a surface under this type of damage.

Several measurement techniques are described, according to the following procedures:

- Constant force scratch test

Single movement of a normally loaded probe (constant force) onto a test piece; friction force and displacement of the probe (relative to the test piece) are measured along the scratch path.

- Ramped force scratch test

Single movement of a progressively normally loaded probe (ramped force) onto a test piece; friction force and displacement of the probe (relative to the test piece) are measured along the scratch path.

- Multi-pass unidirectional constant force scratch test

Repeated movement of a normally loaded probe (constant force) onto a test piece, following the same track; the variation in friction force and displacement of the probe (relative to the piece test) are measured along the scratch path. First introduced by Bull and Rickerby [1], this test is also called “nanowear” when used in the nano scratch range and provides information regarding the fatigue behaviour of the test piece as an effective low cycle fatigue test.

- Progressive force “3-scan” scratch test

Three repetitive unidirectional movement of a normally loaded probe onto a test piece, along the same track. The first movement of the probe is carried out at constant force (low force) and performed as a topography scan of a non-scratched test piece surface. The second movement of the probe is achieved with a progressively increased normal force onto the test piece (from low to high forces). The third movement of the probe is similar to the first movement, at low force, to acquire a topography of the scratch carried out in the test piece. This test is also called “scratch topography multi-pass test” and was first reported by Wu and co-workers [2], [3], which enables identification of failure mechanisms and provides more details regarding the impact of stress such as the critical force for onset of non-elastic deformation and the yield pressure (estimated from mean pressure at critical force).

1 Scope

This document specifies a method for measuring the scratch resistance and failure behaviour for advanced materials and coatings by means of nano- and micro- scale scratch experiments. The method provides data on both the physical damage to test-pieces and the friction generated between the probe and the test-piece under single pass and multiple pass conditions. The force range in these tests is from 1 μ N up to 2 N.

The test method is not applicable to coatings as defined in EN ISO 4618 [18].

2 Normative references

There are no normative references in this document.

3 Terms and definitions

For the purposes of this document, the following terms and definitions apply.

ISO and IEC maintain terminological databases for use in standardization at the following addresses:

- ISO Online browsing platform: available at <https://www.iso.org/obp>
- IEC Electropedia: available at <https://www.electropedia.org/>

3.1

nanoscale

size range between approximately 1 nm and 100 nm

Note 1 to entry: Properties that are not extrapolations from a larger size are predominately exhibited in this size range.

Note 2 to entry: The lower limit in this definition (approximately 1 nm) is introduced to avoid single and small groups of atoms from being designated as nano-objects or elements of nanostructures, which might be implied by the absence of a lower limit.

Note 3 to entry: EN ISO 14577-1 defines nano range for indentation depth as less than 200 nm and has a force criterion for tests in the micro range.

[SOURCE: CEN ISO/TS 80004-1:2015, 2.1 [17], modified]

3.2

microscale

size range between 100 nm and 100 μ m

3.3

topographical profiling

scans carried out for topographical profiling sequence (e.g. 3-pass scratch test: pre-scanning and post-scanning under minimal force), the purpose of which is to measure the topographical profile of the surface before and after the scratch test

Note 1 to entry: The load of the scan should be kept to a minimum to avoid plastic deformation.

Note 2 to entry: Scans have to move in the same direction to avoid uncertainties in displacement recording and scanning movements have to be longer than scratching ones to cover the starting- and ending part of the scratch and providing undeformed areas for checking instrument drift. The force during the scanning movements shall be low enough to ensure that any deformation is elastic.

Note 3 to entry: The probe radius needs to be small enough to give sufficient resolution for the analysis of the profile of the surface.

This is a free preview. Purchase the entire publication at the link below:

[Product Page](#)

-
- Looking for additional Standards? Visit Intertek Inform Infostore
 - Learn about LexConnect, All Jurisdictions, Standards referenced in Australian legislation
-